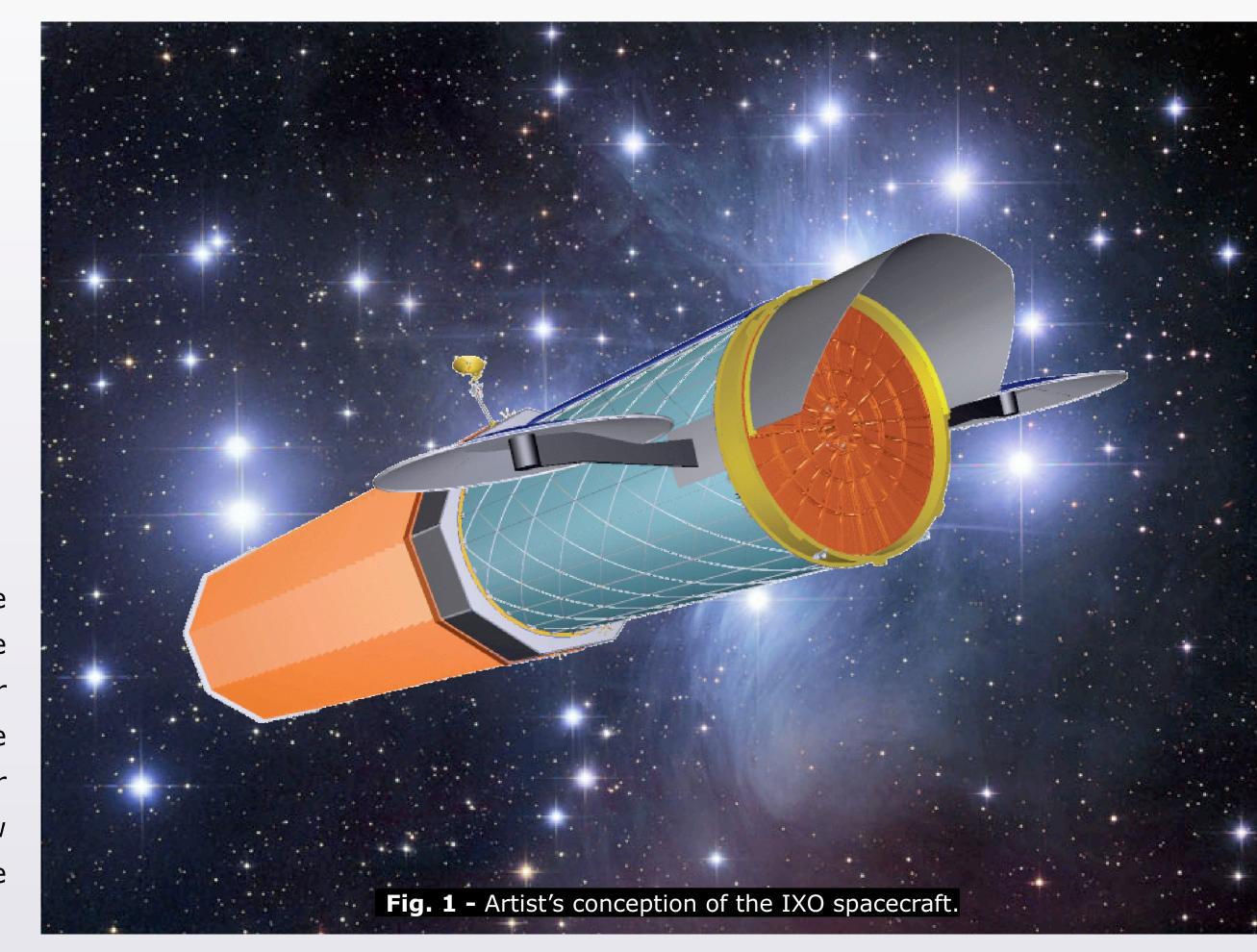
# International X-ray Observatory (IXO)

# The Wide Field Imager for the International X-ray Observatory

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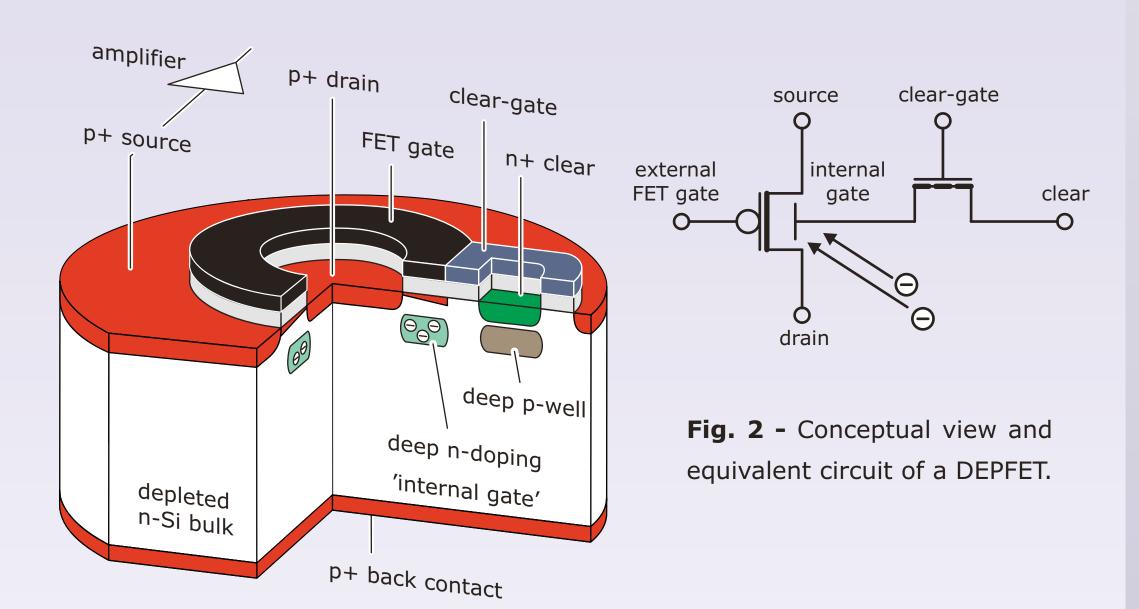
#### Introduction

Since May 2008 the International X-ray Observatory (IXO) mission is under assessment as a joint European-Japanese-American unified vision of the previously independent projects XEUS and Constellation-X with an intended launch date around 2020. IXO aims to study the high-energy universe with unprecedented sensitivity using large-area, high-resolution X-ray optics on a deployable optical bench and interchangeable complementary sensor systems. The focal plane instrumentation includes a micro-calorimeter, a wide field imager, a grating spectrometer, a hard X-ray camera, a high time resolution spectrometer, and an X-ray polarimeter. For the Wide Field Imager (WFI) the X-ray optics with large collecting area and good angular resolution, the wide bandwidth, the required high radiation tolerance and high-speed flexible readout have stimulated the development of a new detector. The baseline WFI option is a monolithic, back-illuminated silicon Active Pixel Sensor based on the integrated detector-amplifier structure DePFET which unifies the science driven specifications in one device. A first series of prototype devices is in compliance with the IXO specifications.



#### The DePFET principle

The DePFET (Depleted P-channel Field Effect Transistor) is an integrated detector-amplifier device. It consits of a p-channel FET on a n-type bulk that is fully depleted by a reverse biased backside diode. The applied voltages and deep implantations generate a local potential minimum for electrons underneath the transistor channel. Signal electrons are collected in this 'internal gate' and modulate the transistor current by inducing positive image charges in the p-channel, and the FET current is a function of the energy absorbed in the depleted volume.



Periodic clocking of the adjacent n-doped clear contact and clear-gate to a positive voltage resets the DePFET, the signal charges are removed from the internal gate.

The DePFET concept combines unique device properties:

- internal amplification
- free of interconnection stray capacitances,
- $\blacktriangleright$  sensitivity of the internal gate  $\Delta I = 300$  pA/electron,
- analog signal storage
- signal collection in ON and OFF state,
- readout on demand,
- full depletion
- backside illumination,
- ▶ high detection efficiency (450 µm Si, 97 / 35 % @ 10 / 20 keV).

#### The DePFET-based Active Pixel Sensor

The matrix arrangement of a number of DePFETs with common bulk and back contact results in an Active Pixel Sensor (APS) with

- in-pixel signal storage and amplification,
- 100 % fill factor, no insensitive regions,
- back-illumination through a homogeneous thin entrance window,
- scalable pixel size from 30  $\mu$ m  $\Box$  to 1 cm<sup>2</sup>  $\Box$ ,
- low power, as the DePFET is only turned on for readout,
- random accessible pixels allowing flexible readout modes:
  - sequential, CCD-like full frame mode,
  - window mode with free selectable regions of interest,
  - mixed mode, combined window & full frame mode,
- ▶ fast timing mode, max. readout speed on a limited area with reduced energy resolution (e.g. 10<sup>5</sup> counts/sec, 16 x 16 pixels),

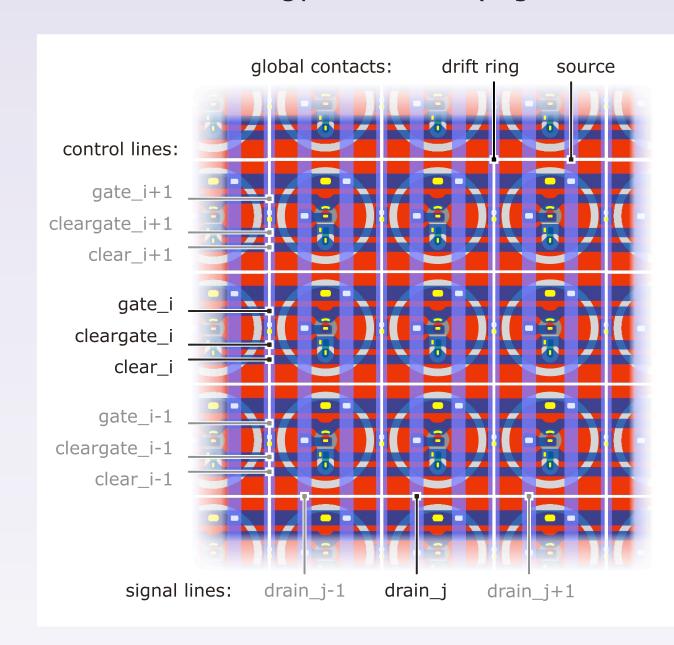


Fig. 3 - 3 x 3 pixel detail of the IXO-WFI tentative layout with a pixel format of 100  $\mu m$   $\square$ . For optimal signal charge collection and efficient area-filling the DePFETs have a circular shape and are surrounded by a drift ring structure focusing the signal electrons towards the pixel center.

#### column-parallel readout:

- row-wise connection of control contacts (gate, clear, clear-gate),
- column-wise connection of readout nodes, i.e. drain contacts,
- global contacts (source, drift ring, substrate, back contact),
- cyclic readout:
- one active row with DePFETs turned on,
- active row is scrolled cyclically through the pixel matrix,
- other DePFETs turned off, still integrating signals,

The IXO Wide Field Imager

scientific and technical boundary conditions:

▶ sensor dimension > 10 x 10 cm<sup>2</sup>,

▶ in total ~ 1 million pixels,

raw data rate 2 GByte/sec

monolithic device,

control chips \_

64 x 64 pixel\_

readout chips.

100 x 100 μm<sup>2</sup>

bright point source observation

, , , ,

• energy range 100 eV ... 15 keV

 $\blacktriangleright$  integration time = (number of pixel rows) x (row processing time).

The specifications of the IXO Wide Field Imager are driven by top-level

world's largest monolithic X-ray imaging & spectroscopy sensor,

• angular resolution 5 arcsec (= point spread function 500 µm HEW)

▶ FoV coverage: > 99.8 % @ 18 arcmin, > 90 % @ 20 arcmin,

 $\blacktriangleright$  pixel size 100 x 100  $\mu$ m<sup>2</sup>, 5 x oversampling of the HEW,

ultra-thin radiation entrance window for low energies,

efficient on-board data reduction algorithm required,

window mode with free selectable region of interest,

suspension mounting without mechanical support.

combination with hard energy X-ray camera

• photon flux (sampling area 3 m<sup>2</sup> @ 1.25 keV, 1 m<sup>2</sup> @ 6 keV)

column-parallel bi-directional readout, 2048 readout channels,

2 μsec readout time per pixel row, full frame rate 1.000/sec,

▶ full depletion of 450 µm Si for high energies,

• field of view (FoV) > 18 arcmin (@ focal length 20 m)

▶ 6' wafer-scale device with 'round' corners (fig. 7),

#### Frontend Electronics

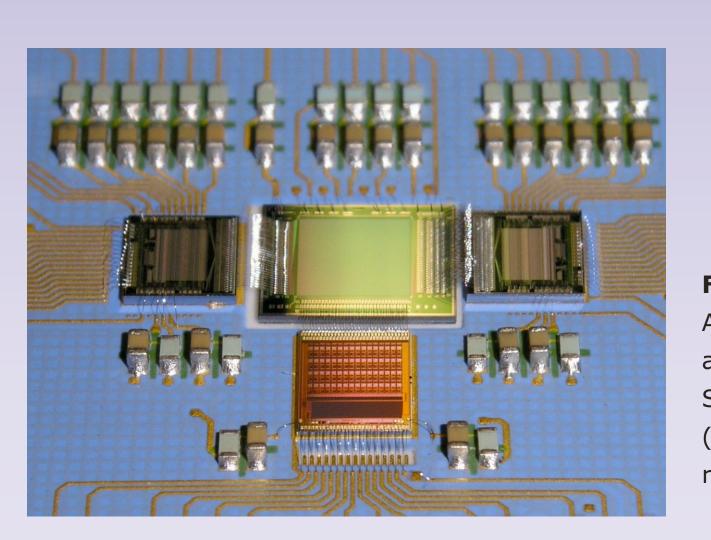


Fig. 4 - Prototype DePFET APS with 75  $\mu$ m  $\square$  pixels and 64 x 64 format (middle), SWITCHER-II control chips (left and right), and VELA readout chip (bottom).

#### **Readout sequence**

A measurement of the DePFET current retrieves the signal information stored in the internal gate in a consecutive read-clear-read sequence:

- 1. first current measurement: baseline + signal
- 2. reset, i.e. removal of signal charges by clocking clear and clear-gate,
- 3. second current measurement: baseline. The signal amplitude is obtained from the current difference.

#### **VELA readout chip** (Politecnico di Milano)

- DePFET-specific development,
- 64-channel pre-amplifier & filter-amplifier, 64/1 analog multiplexer,
- current (de)integration filter with trapezoidal weighting function,
- high dynamic range by current subtraction circuit,
- fast readout: 2 μsec processing time per pixel row (and even below),
- tradeoff: readout speed vs. equivalent noise charge,
- $\blacktriangleright$  ENC = 4 el. @ 4 µsec/row,
- $\rightarrow$  ENC = 7 el. @ 2 µsec/row.

#### **SWITCHER** control chip

- DePFET-specific development,
- 64-channel dual-output switching circuit,
- supply of clocked analog voltages applied to gate, clear, clear-gate,
- high-voltage CMOS process, switching amplitude > 20 V,
- switching frequency > 20 MHz,
- daisy-chainable for the operation of large format APSs.

## **Prototypes**

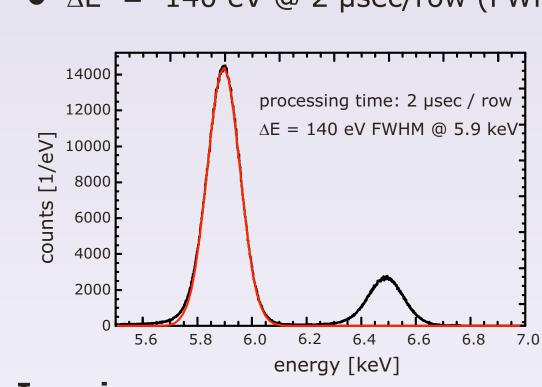
Prototype devices (fig. 4) with 64 x 64 pixels, 75 x 75  $\mu$ m<sup>2</sup> pixel size, and 450 µm wafer thickness have been fabricated in a dedicated process technology including two poly-silicon layers and two metal layers and characterised at IXO-representative conditions at -60 °C with a readout speed of 2 µsec per pixel row.

#### **Process quality**

- leakage current level 10 fA/pixel @ RT (~ 100 pA/cm² @ RT),
- offset and gain variation < 3 %, noise dispersion < 10 %,</li>
- no dead or bright pixels.

#### **Spectral resolution**

- $\Delta E = 126 \text{ eV} @ 4 \mu \text{sec/row} (FWHM @ 5.9 \text{ keV, -60 °C}),$
- $\Delta E = 140 \text{ eV} \oplus 2 \mu \text{sec/row} \text{ (FWHM } \oplus 5.9 \text{ keV, -60 °C)}.$



**Fig. 5 -** 55 Fe spectrum obtained with a 64 x 64 DEPFET APS at -60 °C with VELA readout and fast processing time of 2 µsec per pixel row. The FWHM of the Mn-K $\alpha$  line is 140 eV.

**Imaging** 

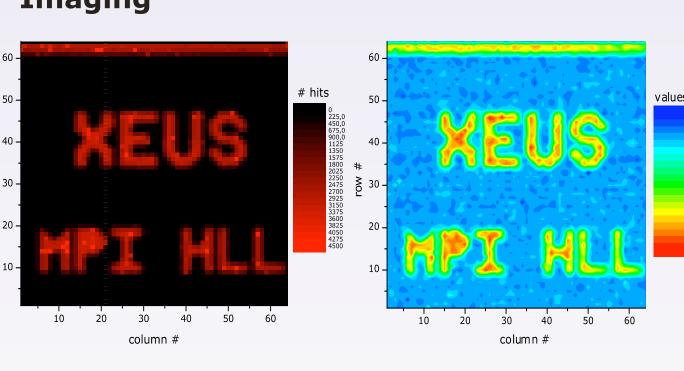


Fig. 6 - Shadow image of a Si mask: digital hit map (right), analog contour plot (left). The images contain 10<sup>5</sup> frames. The smallest feature size is 150 µm.

#### **Radiation hardness**

The DePFET is intrinsically radiation hard, as - unlike a CCD - there is no charge transport within the device. The leakage current generated by bulk damage is controlled through the operation temperature -60 °C and by the fast readout. Proton and X-ray irradiations have been performed:

- negligible leakage current @ 10<sup>10</sup> p/cm<sup>2</sup> (10 MeV), tolerable threshold voltage shift < 1 V @ 10 krad.</li>

**MPI** Halbleiterlabor Otto-Hahn-Ring 6, D-81739 München, Germany www.hll.mpg.de

\_max. fill area

Fig. 7 - Tentative layout of the

IXO-WFI focal plane detector with

1 million pixels of 100 µm □ size

on a 6-inch silicon wafer. The

outer dimensions of the sensitive

area are 10.24 x 10.24 cm<sup>2</sup>. The

squares are blocks of 64 x 64

pixels. The white arrows indicate

the parallel bidirectional readout.

### Next Steps

In a second production DePFET APS prototypes with representative large sensor formats have been processed (fig. 8):

- 75 µm  $\square$  pixels, 256 x 256 pixels, 1.92 x 1.92 cm<sup>2</sup> sensitive area,
- 75  $\mu$ m  $\square$  pixels, 128 x 512 pixels, 0.96 x 3.84 cm<sup>2</sup> sensitive area.

Their characterisation is in preparation with the intention to demonstrate the homogeneity of large scale devices and the technology readiness of the DePFET approach for IXO.

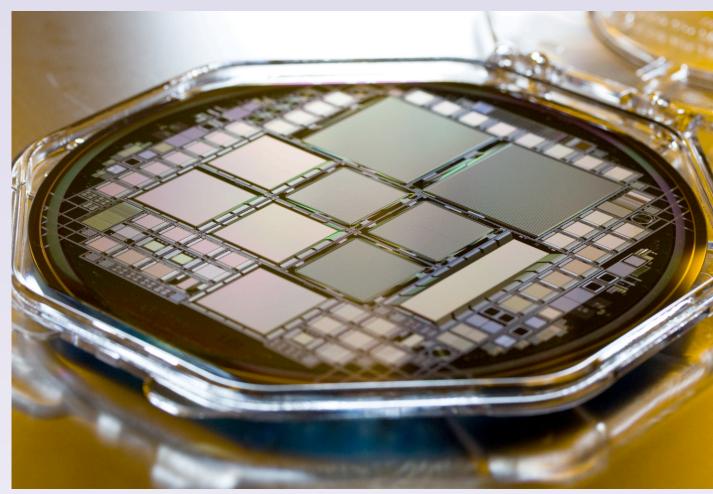


Fig. 8 - 6-inch Si wafer with APS prototypes for the IXO-WFI studies. The sensor formats are 256 x 256 pixels and 128 x 512 pixels with 75 µm □ pixel size.

# Summary

- For the Wide Field Imager of the IXO mission we propose a wafer scale DePFET Active Pixel Sensor.
- The DePFET concept unifies the science driven top level requirements of IXO in one device.
- A dedicated process technology for the fabrication of DePFET APSs has been successfully applied in several prototype runs.

A DePFET-specific frontend electronics system of readout and control

- chips has been developed. A laboratory data acquisition system scalable for the operation of large
- The concept of the sensor and frontend electronics has been proven by 64 x 64 prototypes with performance figures in accordance with the requirements of the IXO mission.
- A new generation of sensors with significantly larger formats is available for the demonstration of the DePFET technology readiness.

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sensor formats has been installed.